

PATENT APPLICATION

Sheet 1 of 1

FORM PTO-1449 LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)	ATTY. DOCKET NO. 10004405-6	SERIAL NO. 10/608,644
	APPLICANT Duane Fasen et al	
	FILING DATE 6/27/2003	GROUP 2826

REFERENCE DESIGNATION

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	*	DOCUMENT NUMBER	DATE	NAME
JA		6,184,055	Feb 6, 2001	Yang et al
JA		6,060,732	May 9, 2000	Murakami et al
JA		6,048,662	Apr 11, 2000	Bruhnke et al
JA		5,990,506	Nov 23, 1999	Fossum et al
JA		5,654,202	Aug 5, 1997	Daly et al
JA		4,855,199	Aug 8, 1989	Bolon et al
JA		4,782,009	Nov 1, 1988	Bolob et al
JA		5,258,608	Nov 2, 1993	Uchiya
JA		5,266,501	Nov 30, 1993	Imai

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	NAME	TRANSLATION	
					YES	NO

OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, etc.)

EXAMINER John McPherson	DATE CONSIDERED 8/24/04
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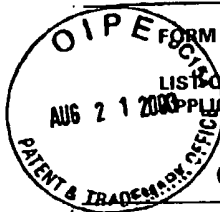
* Copies of these references are not enclosed pursuant to 37 CFR 1.98(d). (See accompanying IDS)

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** TOTAL PAGE.02 **

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STATEMENT

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					YES	NO
JA		WO 97/46915	Dec 11, 1997	Rahman, M., Dalil et al		X
JA		JP11-1030371	Apr 13, 1999	Fukusho Takashi Asai Atsushi	X	

OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, etc.)

JA	"Production Metrology and Control of color filter array photolithography for CMOS imagers", SPIE Vol. 3677, pp. 326-337 (1999)
JA	"Color filter array for CCD and CMOS image sensors using a chemically amplified, thermally cured, pre-dyed, positive-tone photoresist for 365 nm lithography", SPIE Vol. 3678, pp.1083-1090 (1999)
JA	"Advanced complementary color filter technology without dyeing process for CCD image sensors", SPIE Vol. 3333, pp.1232-1240 (1998)

EXAMINER

John McPherson

DATE CONSIDERED

8/24/04

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